

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:)
Shinji MAEKAWA et al.) Confirmation No.: 3488
Application No. 10/579,800) Examiner: Hoai V. Pham
Filed: May 19, 2006) Group Art Unit: 2892
For: ELECTRIC APPLIANCE)
SEMICONDUCTOR DEVICE, AND) Date: August 21, 2008
METHOD FOR MANUFACTURING THE
SAME

RESPONSE TO REQUEST FOR RESTRICTION REQUIREMENT

Mail Stop: Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Request for Restriction Response mailed July 24, 2008, Applicant responds as follows.

REMARKS

The Office Action of July 24, 2008 was received and carefully reviewed. Applicant hereby elects without traverse, Group I, Claims 1-18, drawn to a method for manufacturing a semiconductor device.

Consideration and allowance of the instant application are now respectfully requested.

Respectfully submitted,

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